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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/757,974	01/15/2004	Jenoe Tihanyi	1890-0033	4260	
7590 01/09/2006		EXAMINER			
Maginot, Moore & Beck			NGUYER	NGUYEN, HIEP	
Bank One Towe	r				
111 Monument	Circle, Suite 3000	ART UNIT	PAPER NUMBER		
Indianapolis, IN 46204			2816		
		DATE MAIL ED: 01/00/2006			

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
	10/757,974	TIHANYI, JENOE					
Office Action Summary	Examiner	Art Unit					
	Hiep Nguyen	2816					
The MAILING DATE of this communication ap Period for Reply	opears on the cover sheet with the	he correspondence address					
A SHORTENED STATUTORY PERIOD FOR REPI WHICHEVER IS LONGER, FROM THE MAILING [- Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICAT .136(a). In no event, however, may a reply to d will apply and will expire SIX (6) MONTHS tte, cause the application to become ABAND	ION. be timely filed from the mailing date of this communication. ONED (35 U.S.C. § 133).					
Status							
1)⊠ Responsive to communication(s) filed on 08 i	November 2005						
,— .	<u> </u>						
<u>, </u>							
	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
4)⊠ Claim(s) <u>15 and 17-34</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>15 and 17-34</u> is/are rejected.	6)⊠ Claim(s) <u>15 and 17-34</u> is/are rejected.						
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/	or election requirement.						
Application Papers							
9)☐ The specification is objected to by the Examin	ner.						
10)⊠ The drawing(s) filed on <u>15 January 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
Applicant may not request that any objection to the	e drawing(s) be held in abeyance.	See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the corre	ction is required if the drawing(s) is	s objected to. See 37 CFR 1.121(d).					
11)☐ The oath or declaration is objected to by the E	Examiner. Note the attached Of	fice Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreiga) All b) Some * c) None of:		9(a)-(d) or (f).					
<u> </u>	1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No							
3. Copies of the certified copies of the pri	·	eived in this National Stage					
application from the International Burea							
* See the attached detailed Office action for a lis	st of the certified copies not reco	eivea.					
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Sumn	nary (PTO-413)					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Ma	ail Date					
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 		nal Patent Application (PTO-152) I <u>paper (20030006829A1)</u> .					

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DETAILED ACTION

Claim Objections

Claim 19 is objected to because of the following informalities: claim 19 depends upon rejected claim 16. Thus, the Examiner assumes that claim 19 depends upon claim 15. The recitation "the constant voltage element" in claim 17 lacks antecedent basis.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 15 and 17-34 are rejected under 35 U.S.C. 103(a) as being unpatentable over Alessandria et al. (US 2003/0006892A1) in view of Kimura (USP. 6,851,849), Hartwick (USP. 4,881,024), Kumar (USP. 6,855, 981), Zeiler (USP. 4,937,470) and Pavlin (USP. 5,438,286). See attached paper.

Regarding claim 15, figure 10 of Alessandria shows a MOSFET circuit comprising: a first MOS transistor (23), a second MOS transistor (22) connected in parallel, a Zener diode (20) coupled between the gates of the first and second MOS transistors. Figur 2 of Pavlin shows a MOSFET circuit comprising a first transistor (TP1) and a second transistor (TP2) wherein the second transistor has less cells than the first transistor (col. 3, lines 32-50). The circuit taught by Pavlin has lower threshold current than the circuit having two transistors having an equal number of cells (col. 4, lines 41-62). Therefore, it would have been obvious for one of ordinary skill in the art to replace transistors (22) and (23) of Alessandria with the transistors taught by Pavlin for lowering the threshold current.

Regarding claims 17, 18 and 19, the combination of Alessandria and Pavlin includes all the limitation of these claims except for the limitation that the circuit further comprises a

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resistor connected in parallel with the Zener diode. The circuit of circuit of Alessandria has a limitation that the voltage applied to the gate of transistor (22) only happens when the input voltage (Vin) is high enough to reverse biased Zener (20). Figure 1 of Zeiler shows a Zener diode (44) having a resistor (46) coupled in parallel with it for continuously controlling the the first MOS transistor (48) and for limiting the voltage applied to the gate of the first MOS transistor. Therefore, it would have been obvious for one of ordinary skill in the art to replace the single diode (20) of Alessandria with the diode and the resistor taught by Zeiler for continuously controlling the first MOS transistor (48) and for limiting the voltage applied to the gate of the transistor. The second resistor is resistor (R2).

Regarding claim 20, the combination of Alessandria, Pavlin and Zeiler includes all the limitations of claim 17 except for the limitation that that the zener diode (44) and the resistor (46) are integrated with one another for having a compact circuit. Therefore, it would have been obvious for one of ordinary skill in the art to integrate the zener diode (44) with the resistor (46) for having a compact circuit.

Regarding claims 21, 22, 23 and 32, the technique of fabrication of the zener diode and the resistor are well known in the art and is fully shown by Kumar (6,855, 981, col. 11, lines 24-30). Kumar does not show that "the dope concentration of the highly doped layer is less than 10exp 19 charge carrier cm -exp 3". However, it is old and well known and it would have been an obvious matter of preference bounded by well known manufacturing constraints and ascertainable by routine experimentation and optimization to choose the particular claimed relative predetermined value of a differential input voltage limitations because applicant has not disclosed that the limitations are for a particular unobvious purpose, produce an unexpected result, or are otherwise critical, and it appears prima facie that the process would possess utility using another relative predetermined value of a differential input voltage. Indeed, it has been held that optimization of range limitations are prima facie obvious absent a disclosure that the limitations are for a particular unobvious purpose, produce an unexpected result, or are otherwise critical. See MPEP 2144.05(II): "Generally, differences in concentration or temperature will not support the patentability of subject matter encompassed by the prior art unless there is evidence indicating such concentration or temperature is critical. '[W]here the general conditions of a claim are disclosed in the prior art, it is not

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inventive to discover the optimum or workable ranges by routine experimentation." In re Aller, 220 F.2d 454, 105 USPQ 233, 235 (CCPA 1955). See also In re Hoeschele, 406 F.2d 1403, 160 USPQ 809 (CCPA 1969), Merck & Co. Inc. v. Biocraft Laboratories Inc., 874 F.2d 804, 10 USPQ2d 1843 (Fed. Cir.), cert. denied, 493 U.S. 975 (1989), and In re Kulling, 897 F.2d 1147, 14 USPQ2d 1056 (Fed. Cir. 1990) as set forth in MPEP 2144.05(III). Therefore, it would have been obvious to one having ordinary skill in the art to select the dope concentration of the highly doped layer to be less than 10exp19 charge carrier cm —exp 3" dependent upon particular environment of use to ensure optimum performance.

Regarding claims 24, figure 10 of Alessandria shows a MOSFET circuit comprising: a first MOS transistor (23), a second transistor (22) coupled in parallel with the first MOS transistor, a constant voltage element is a Zener diode (20). Figure 10 of Alessandria does not show that the first MOS transistor has a first number of cells and the second MOS transistor has a second number of cells. Figure 2 of Pavlin shows a MOSFET circuit comprising first second MOS transistor (TP1) and second NMOS transistor (TP2) coupled in parallel. The second transistor (TP2) has a second number of cells less (10-40 times) than the first number of cells (col. 4, lines 35-40) for providing a circuit having low threshold current that is many times lower than the circuit of Alessandria wherein the transistors have an equal number of cells. (col. 4, lines 50-62). Therefore, it would have been obvious for one of ordinary skill in the art to replace the transistors of Alessandria with the transistors taught by Pavlin for providing a circuit having low threshold current that is many times lower than circuit wherein the transistors have an equal number of cells. The resistor is element (R2).

Regarding claims 25-27 and 29, the first number of cells is 10 to 40 times larger than the second number of cells (col. 4, lines 35-40). The first number of cells is from 15,000 to 20,000 (col. 4, lines 38-40).

Regarding claim 28, transistors (TP1) and (TP2) of Pavlin constitute a main composite transistor (TP) that is used to compensate the threshold current by lowering it X times lower (col. 4, lines 50-62).

Regarding claims 30, figure 10 of Alessandria shows a MOSFET circuit comprising: a first MOS transistor (23), a second transistor (22) coupled in parallel with the first MOS transistor, a constant voltage element is a zener diode. Figure 3 of Alessandria does not show

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that the first MOS transistor has a first number of cells and the second MOS transistor has a second number of cells. Figure 2 of Pavlin shows a MOSFET circuit comprising first second MOS transistor (TP1) and second NMOS transistor (TP2) coupled in parallel. The second transistor (TP2) has a second number of cells less (10-40 times) than the first number of cells (col. 4, lines 35-40) for providing a circuit having low threshold current that is many times lower than the circuit of Alessandria wherein the transistors have an equal number of cells. (col. 4, lines 50-62). Therefore, it would have been obvious for one of ordinary skill in the art to replace the transistors of Alessandria with the transistors taught by Pavlin for providing a circuit having low threshold current that is many times lower than circuit wherein the transistors have an equal number of cells. The resistor is element (R2). Even though, Alessandria does not mention that the zener diode is fabricated with a technique recited in claim 30. However, this technique is a common technique shown in US Pat. 6,855,981, col. 11, lines 23-44.

Regarding claim 31, the resistor is element (R2). Kuma col. 11 shows that the resistor can be formed by the pn junction between the polycrystalline layer and the zone.

Regarding claims 33 and 34, the first number of cells is 10 to 40 times larger than the second number of cells (col. 4, lines 35-40). The first number of cells is from 15,000 to 20,000 (col. 4, lines 38-40).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hiep Nguyen whose telephone number is (571) 272-1752. The examiner can normally be reached on Monday to Friday from 7:30am to 4:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Callahan can be reached on (571) 272-1740. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Hiep Nguyen

12-30-05

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